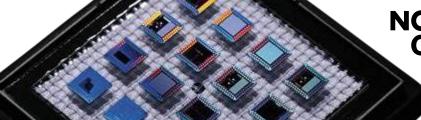
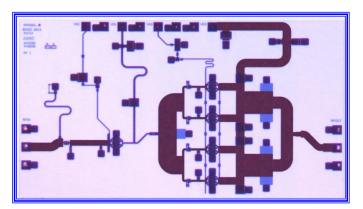
APN229 27 - 31 GHz GaN Power Amplified



NORTHROP GRUMMAN

Revision 2022-1



x=3.65mm; y=2.03 mm

Product Description

The APN229 monolithic GaN HEMT amplifier is a broadband, two-stage power device, designed for use in SATCOM Terminals and point-to-point digital radios. To ensure rugged and reliable operation, HEMT devices are fully passivated. Both bond pad and backside metallization are Au-based that is compatible with epoxy and eutectic die attach methods.

Applications

- Point-to-Point Digital Radios
- Point-to-Multipoint Digital Radios
- SATCOM Terminals

Product Features

■RF frequency: 27 to 31 GHz

■ Linear Gain: 20 dB typ.

■ Psat: 39 dBm typ.

■ Die Size: 7.41 sq. mm.

0.2um GaN HEMT Process

4 mil SiC substrate

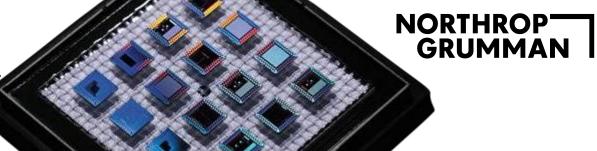
■ DC Power: 28 VDC @ 600 mA

Export Information ECCN: 3A001.b.2.c

HTS (Schedule B) code: 8542.33.0001

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APN229 27 – 31 GHz GaN Power Amplifier



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Absolute Maximum Ratings

Parameter	Value	Unit
Drain Voltage	28	V
Gate Voltage Range	-8 to 0	V
Drain Current	750	mA
Gate Current	0.3	mA
Power Dissipation*	21	W
Soldering Temperature	320	°C

^{*7}W/mm of gate periphery

Recommended Operating Conditions

Parameter		Unit
Drain Voltage Range	20 - 26	V
Gate Voltage Range	-5 to -3	V
Stg 1 Drain Current (Idq)	120	mA
Stg 2 Drain Current (Idq)	120 – 480	mA

Electrical Specifications

Parameter	Min	Тур	Max	Unit			
Operational Frequency	27		30	GHz			
Small Signal at 28V							
Small Signal Linear Gain	20	21.2	20.7	dB			
Input Return Loss	30.1		-11	dB			
Output Return Loss	-30.8		-5.5	dB			
	On-Wafer Pulsed Power at 28V						
Psat (at 26 dBm)	37.7	38.6	39.3	dBm			
Power Gain (at 26 dBm)	11	12.6	13.3	dB			
P1db	35	35.8	36.6	dBm			
PAE (at 26 dBm)	24.2	29.1	31.7	%			
Max PAE	35.7	29.9	31.7	%			
F	Fixtured CW at 24V, 25°C Case Temp						
Psat (at 26 dBm)	37.4	38.1	39.3	dBm			
Power Gain (at 26 dBm)	11.5	12.2	13.4	dB			
PAE (at 26 dBm)	22.2	26	32.9	%			
Max PAE	24	28.3	33.8	%			
Drain Voltage		28		V			
Stage 1 Gate Voltage		-4.060		V			
Stage 2 Gate Voltage		-4.125		V			
Stage 1 Idq		120		mA			
Stage 2 Idq		480		mA			

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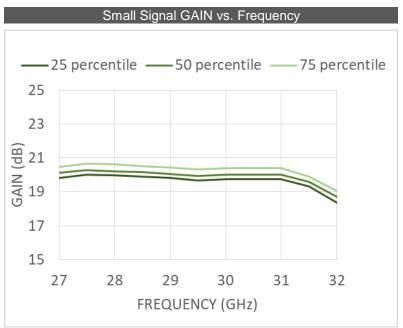
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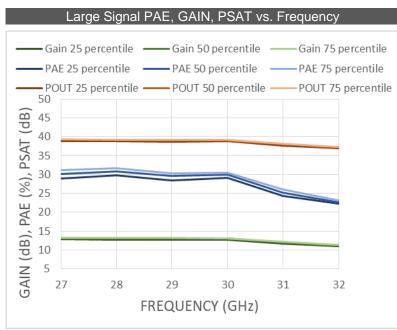


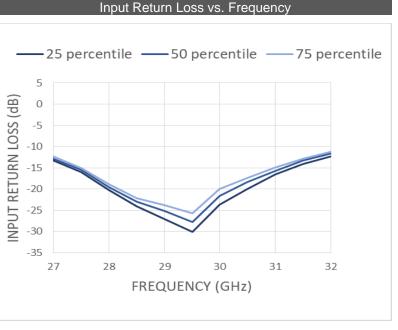
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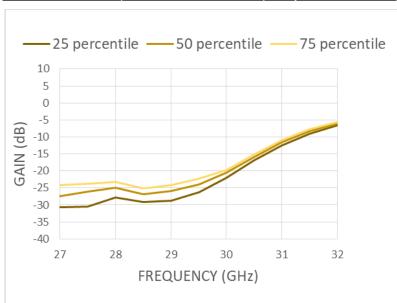
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On wafer measured Performance Characteristics (Typical Performance at 25°C) Vd = 28.0 V, Id1 + Id1a = 120mA, Id2 + Id2a = 480 mA





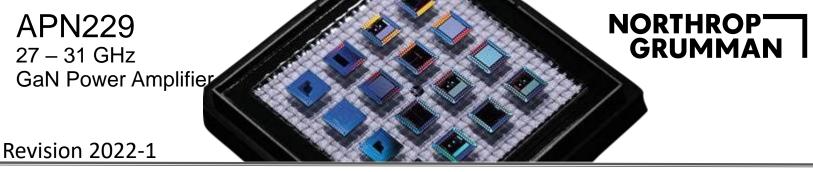




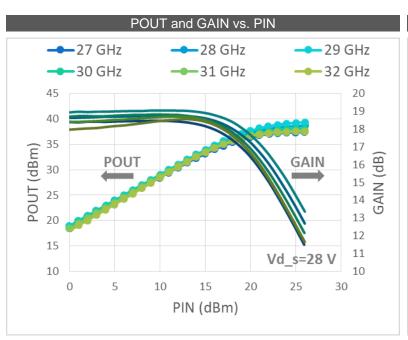
Output Return Loss vs. Frequency

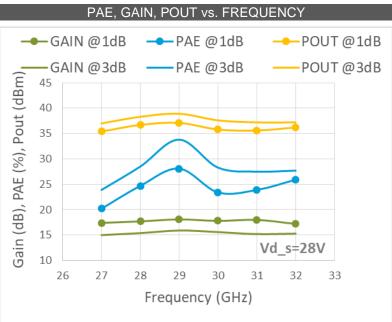
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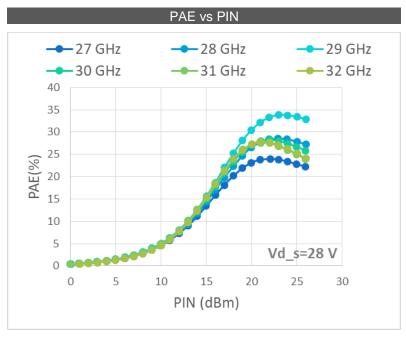
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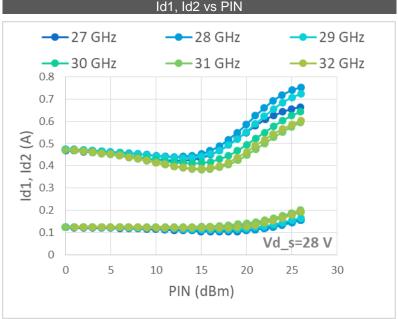


Fixture measured Performance Characteristics (Typical Performance at 25°C) Vd = 28.0 V, Id1 + Id1a = 120 mA, Id2 + Id2a = 480 mA









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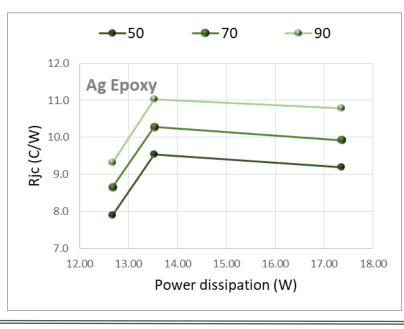
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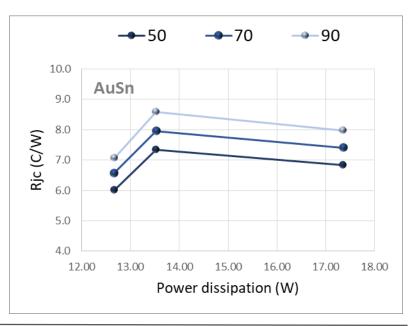
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Preliminary Thermal Properties with die mounted with 25um 80/20 AuSn Eutectic to: 10mil Cu10W Shim.

** Vd = 28.0 V, Idq1 = 120 mA, Id2q = 480mA

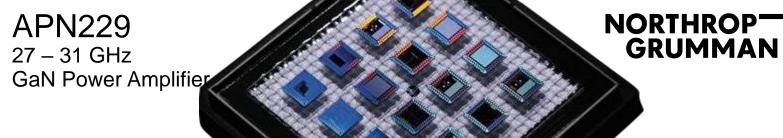
Shim	Mounting Material	Average Backside Die Temperature	Hottest Junction Temperature Tjc	RF Output	Power Dissipation (W)	Thermal Resistance Rjc (ºC/W)
10 mil CuW	AuSn Eutectic	50 °C	126.1	32.98	12.67	6.0
			149.2	36.4	13.52	7.3
			168.8	39.25	17.36	6.8
		70 °C	153.2	32.98	12.67	6.6
			177.6	36.4	13.52	8.0
			198.6	39.25	17.36	7.4
		90 °C	179.5	32.98	12.67	7.1
			206.1	36.4	13.52	8.6
			228.3	39.25	17.36	8.0
10 mil CuW	Ag Epoxy	50 °C	149.9	32.98	12.67	7.9
			179.0	36.4	13.52	9.5
			209.4	39.25	17.36	9.2
		70 °C	179.6	32.98	12.67	8.7
			208.9	36.4	13.52	10.3
			242.2	39.25	17.36	9.9
		90 °C	239.1	33.2	12.67	9.3
			208.1	36.4	13.52	11.0
			277.1	39.25	17.36	10.8





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Die Size and Bond Pad Locations (Not to Scale)

X=3800 μm \pm 25 μm Y=3800 \pm 25 μm DC Bond Pad = 100 x 100 \pm 0.5 μm RF Bond Pad = 100 x 100 \pm 0.5 μm Chip Thickness = 101 \pm 5 μm

2077 µm 1477 µm-⊢1077 µm**→** 677 µm VG1 GND COND GND GND GND COND GND ■ **RFOUT** GND ■ 3800 um ■ GND ■ RFIN GND 2678 µm 1122 µm 677 µm **←**1077 μm**→** ·1477 μm--2077 µm 3800 um

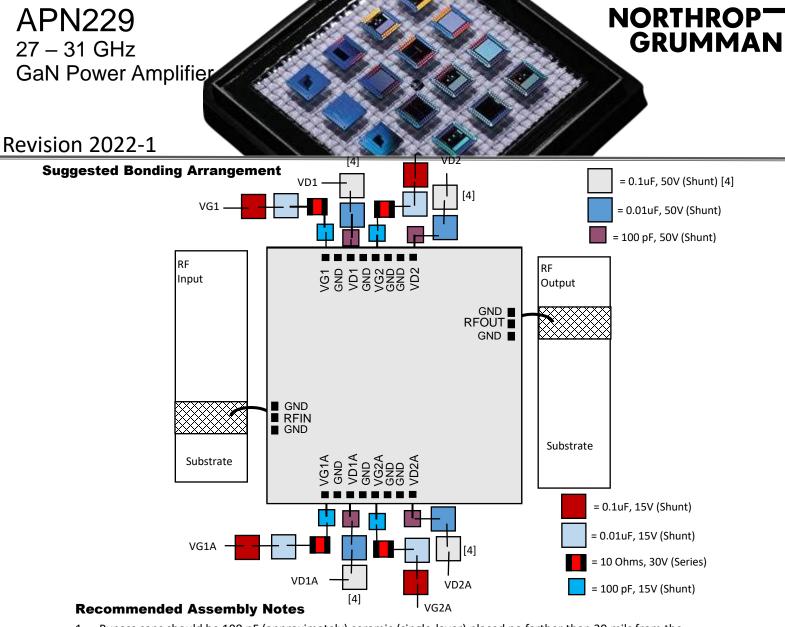
Biasing/De-Biasing Details:

Bias for 1st stage is from top. The 2nd stages must bias up from both sides.

Listed below are some guidelines for GaN device testing and wire bonding:

- a. Limit positive gate bias (G-S or G-D) to < 1V
- b. Know your devices' breakdown voltages
- c. Use a power supply with both voltage and current limit.
- d. With the power supply off and the voltage and current levels at minimum, attach the ground lead to your test fixture.
 - i. Apply negative gate voltage (-5 V) to ensure that all devices are off
 - ii. Ramp up drain bias to ~10 V
 - iii. Gradually increase gate bias voltage while monitoring drain current until 20% of the operating current is achieved
 - iv. Ramp up drain to operating bias
 - v. Gradually increase gate bias voltage while monitoring drain current until the operating current is achieved
- e. To safely de-bias GaN devices, start by debiasing output amplifier stages first (if applicable):
 - i. Gradually decrease drain bias to 0 V.
 - ii. Gradually decrease gate bias to 0 V.
 - iii. Turn off supply voltages
- f. Repeat de-bias procedure for each amplifier stage

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- 1. Bypass caps should be 100 pF (approximately) ceramic (single-layer) placed no farther than 30 mils from the amplifier.
- 2. Best performance obtained from use of <10 mil (long) by 3 by 0.5 mil ribbons on input and output.
- 3. Part must be biased from both sides as indicated.
- 4. The 0.1uF, 50V capacitors are not needed if the drain supply line is clean. If Drain Pulsing of the device is to be used, do **NOT** use the 0.1uF, 50V Capacitors.

Mounting Processes

Most NGSS GaN IC chips have a gold backing and can be mounted successfully using either a conductive epoxy or AuSn attachment. NGSS recommends the use of AuSn for high power devices to provide a good thermal path and a good RF path to ground. Maximum recommended temp during die attach is 320°C for 30 seconds.

Note: Many of the NGSS parts do incorporate airbridges, so caution should be used when determining the pick up tool.

CAUTION: THE IMPROPER USE OF AUSN ATTACHMENT CAN CATASTROPHICALLY DAMAGE GaN CHIPS.

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